10050505 Atty. Dkt. No. 017447-0194

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Koichi WATANABE et al.

Title: SPUTTERING TARGET AND PROCESS FOR PRODUCING Si

OXIDE FILM THEREWITH

Appl. No.: Unassigned

Filing Date: 03/27/2006

Examiner: Unassigned

Art Unit: Unassigned

## PRELIMINARY AMENDMENT UNDER 37 CFR 1.115

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Prior to examination of the present Application, Applicants respectfully request that the application be amended as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this document.

Remarks/Arguments begin on page 4 of this document.

Please amend the application as follows: